Electrochemistry at Metal and Semiconductor Electrodes

By Norio Sato

Electrochemistry at Metal and Semiconductor Electrodes

bγ

Norio Sato

Emeritus Professor, Graduate School of Engineering, Hokkaido University, Sapporo, Japan



Amsterdam – Boston – London – New York – Oxford – Paris – San Diego San Francisco – Singapore – Sydney – Tokyo ELSEVIER SCIENCE B.V.
Sara Burgerhartstraat 25
P.O. Box 211, 1000 AE Amsterdam, The Netherlands

© 1998 Elsevier Science B.V. All rights reserved.

This work is protected under copyright by Elsevier Science, and the following terms and conditions apply to its use:

Photocopying

Single photocopies of single chapters may be made for personal use as allowed by national copyright laws. Permission of the Publisher and payment of a fee is required for all other photocopying, including multiple or systematic copying, copying for advertising or promotional purposes, resale, and all forms of document delivery. Special rates are available for educational institutions that wish to make photocopies for non-profit educational classroom use.

Permissions may be sought directly from Elsevier's Science & Technology Rights Department in Oxford, UK: phone: (+44) 1865 843830, fax: (+44) 1865 853333, e-mail: permissions@elsevier.com. You may also complete your request on-line via the Elsevier Science homepage (http://www.elsevier.com), by selecting 'Customer Support' and then 'Obtaining Permissions'.

In the USA, users may clear permissions and make payments through the Copyright Clearance Center, Inc., 222 Rosewood Drive, Danvers, MA 01923, USA; phone: (+1) (978) 7508400, fax: (+1) (978) 7504744, and in the UK through the Copyright Licensing Agency Rapid Clearance Service (CLARCS), 90 Tottenham Court Road, London W1P 0LP, UK; phone: (+44) 207 631 5555; fax: (+44) 207 631 5500. Other countries may have a local reprographic rights agency for payments.

Derivative Works

Tables of contents may be reproduced for internal circulation, but permission of Elsevier Science is required for external resale or distribution of such material.

Permission of the Publisher is required for all other derivative works, including compilations and translations.

Electronic Storage or Usage

Permission of the Publisher is required to store or use electronically any material contained in this work, including any chapter or part of a chapter.

Except as outlined above, no part of this work may be reproduced, stored in a retrieval system or transmitted in any form or by any means, electronic, mechanical, photocopying, recording or otherwise, without prior written permission of the Publisher.

Address permissions requests to: Elsevier's Science & Technology Rights Department, at the phone, fax and e-mail addresses noted above.

Notice

No responsibility is assumed by the Publisher for any injury and/or damage to persons or property as a matter of products liability, negligence or otherwise, or from any use or operation of any methods, products, instructions or ideas contained in the material herein. Because of rapid advances in the medical sciences, in particular, independent verification of diagnoses and drug dosages should be made.

First edition 1998 Second impression 2003

Library of Congress Cataloging-in-Publication Data

```
Sato, Norio.

Electrochemistry at metal and semiconductor electrodes / by Norio Sato.

p. cm.

Includes bibliographical references (p. - ) and index.
ISBN 0-444-82806-0 (alk. paper)
1. Electrodes, Oxide. 2. Semiconductors. I. Title.
OD572.085S37 1998
541.3'724--dc21 98-36139
```

ISBN: 0 444 82806 0

Electrochemistry
at Metal
and
Semiconductor
Electrodes

PREFACE

Electrochemistry at Electrodes is concerned with the structure of electrical double layers and the characteristic of charge transfer reactions across the electrode/electrolyte interface. The purpose of this text is to integrate modern electrochemistry with semiconductor physics; this approach provides a quantitative basis for understanding electrochemistry at metal and semiconductor electrodes.

Electrons and ions are the principal particles that play the main role in electrochemistry. This text, hence, emphasizes the *energy level concepts* of electrons and ions rather than the phenomenological thermodynamic and kinetic concepts on which most of the classical electrochemistry texts are based. This rationalization of the phenomenological concepts in terms of the physics of semiconductors should enable readers to develop more *atomistic* and *quantitative* insights into processes that occur at electrodes.

This book incorporates into many traditional disciplines of science and engineering such as interfacial chemistry, biochemistry, enzyme chemistry, membrane chemistry, metallurgy, modification of solid interfaces, and materials corrosion.

This text is intended to serve as an introduction for the study of advanced electrochemistry at electrodes and is aimed towards graduates and senior undergraduates studying materials and interfacial chemistry or those beginning research work in the field of electrochemistry.

Chapter 1 introduces a concept of energy levels of particles in physicochemical ensembles. Electrons are Fermi particles whose energy levels are given by the Fermi levels, while ions are Boltzmann particles whose energy is distributed in an exponential Boltzmann function. In Chapter 2 the energy levels of electrons in solid metals, solid semiconductors, and aqueous solutions are discussed. Electrons in metals are in delocalized energy bands; electrons in semiconductors are in delocalized energy bands as well as in localized levels; and redox electrons associated with redox particles in aqueous solutions are in localized levels which are split into occupied (reductant) and vacant (oxidant) electron levels due to the Franck-Condon principle. Chapter 3 introduces the energy levels of ions in gas, liquid, and solid phases. In aqueous solution, the acidic and basic proton levels in water molecules interrelate with proton levels in solute particles such as acetic acid.

In Chapter 4 the physical basis for the *electrode potential* is presented based on the electron and ion levels in the electrodes, and discussion is made on the electronic and ionic electrode potentials. Chapter 5 deals with the structure of

the electrical double layer at the electrode/electrolyte interfaces. The potential of zero charge of metal electrodes and the flat band potential of semiconductor electrodes are shown to be characteristic of individual electrodes. The interface of semiconductor electrodes is described as either in the state of band edge level pinning or in the state of Fermi level pinning. Chapter 6 introduces electrochemical cells for producing electric energy (chemical cells) and chemical substances (electrolytic cells).

In Chapter 7 general kinetics of electrode reactions is presented with kinetic parameters such as stoichiometric number, reaction order, and activation energy. In most cases the affinity of reactions is distributed in multiple steps rather than in a single particular rate step. Chapter 8 discusses the kinetics of electron transfer reactions across the electrode interfaces. Electron transfer proceeds through a quantum mechanical tunneling from an occupied electron level to a vacant electron level. Complexation and adsorption of redox particles influence the rate of electron transfer by shifting the electron level of redox particles. Chapter 9 discusses the kinetics of ion transfer reactions which are based upon activation processes of Boltzmann particles.

Chapter 10 deals with photoelectrode reactions at semiconductor electrodes in which the concentration of minority carriers is increased by photoexcitation, thereby enabling the transfer of electrons to occur that can not proceed in the dark. The concept of quasi-Fermi level is introduced to account for photoenergy gain in semiconductor electrodes. Chapter 11 discusses the coupled electrode (mixed electrode) at which anodic and cathodic reactions occur at the same rate on a single electrode; this concept is illustrated by corroding metal electrodes in aqueous solutions.

I wish to thank the Japan Technical Information Service for approval to reproduce diagrams from a book "Electrode Chemistry" which I authored. Special acknowledgment is due to Professor Dr. Roger W. Staehle who has edited the manuscript. I am also grateful to Dr. Takeji Takeuchi for his help in preparing camera-ready manuscripts. Finally I am grateful to my wife, Yuko, for her constant love and support throughout my career.

Norio Sato.

nouro Sasto

Sapporo, Japan April, 1998

CONTENTS

| CHAPTER 1 | |
|--|----|
| THE ENERGY LEVEL OF PARTICLES | |
| 1.1 Particles and Particle Ensembles | |
| 1.2 Chemical Potential and Electrochemical Potential | 4 |
| 1.3 Electrochemical Potential of Electrons | F |
| 1.4 The Reference Level of Particle Energy | 8 |
| 1.5 Electrostatic Potential of Condensed Phases | |
| 1.6 Energy Levels of Charged Particles in Condensed Phases | 1 |
| References | 13 |
| | |
| CHAPTER 2 | |
| THE ENERGY LEVEL OF ELECTRONS | 1 |
| 2.1 Energy Levels of Electrons in Condensed Phases | 18 |
| 2.2 Electrons in Metals | 19 |
| 2.2.1 Energy bands and the Fermi level | 19 |
| 2.2.2 The real potential and the chemical potential of electrons in metals | 21 |
| 2.3 Electron Energy Bands of Semiconductors | 24 |
| 2.4 Electrons and Holes in Semiconductors | 27 |
| 2.4.1 Intrinsic semiconductors | 27 |
| 2.4.2 n-type and p-type semiconductors | 29 |
| 2.5 Energy Levels of Electrons in Semiconductors | 32 |
| 2.6 Metal Oxides | 35 |
| 2.6.1 Formation of electron energy bands | 35 |
| 2.6.2 Localized electron levels | 38 |
| 2.7 The Surface of Semiconductors | 39 |
| 2.7.1 The surface state | 39 |
| 2.7.2 The space charge layer | 42 |
| 2.7.3 Surface degeneracy (Quasi-metallization of surfaces) | 44 |
| 2.8 Amorphous Semiconductors | 44 |
| 2.9 Electron Energy Bands of Liquid Water | 45 |
| 2.10 Redox Electrons in Aqueous Solution | 47 |
| 2.10.1 Electron levels of gaseous redox particles | 47 |
| 2.10.2 Electron levels of hydrated redox particles | 48 |
| 2.10.3 Fluctuation of electron energy levels | 51 |
| 2.10.4 The Fermi level of hydrated redox electrons | 53 |
| 2.11 The Electron Level of Normal Hydrogen Electrode | 55 |
| References | 58 |
| | |
| CHAPTER 3 | |
| THE ENERGY LEVEL OF IONS | 61 |
| 3.1 Ionic Dissociation of Gaseous Molecules | 61 |
| 3.9 Matel Ion I avale in Solid Matels | |

viii CONTENTS

| 3.2.1 The unitary energy level of surface metal ions | 63 |
|---|-----|
| 3.2.2 Metal ion levels at the surface and in the interior | 65 |
| 3.3 Ion Levels of Covalent Semiconductors | 67 |
| 3.3.1 The unitary level of surface ions | 67 |
| 3.3.2 Ion levels at the surface and in the interior | 69 |
| 3.4 Ion Levels of Compound Semiconductors | 71 |
| 3.4.1 The unitary level of surface ions | 71 |
| 3.4.2 Ion levels at the surface and in the interior | 74 |
| 3.5 Ion Levels in Aqueous Solution | 76 |
| 3.5.1 Levels of hydrated ions | 76 |
| 3.5.2 Proton levels in aqueous solution | 78 |
| 3.6 Thermodynamic Reference Level for Ions | 85 |
| References | 86 |
| | |
| CHAPTER 4 | |
| ELECTRODE POTENTIAL | |
| 4.1 Electrode | |
| 4.1.1 Electrode | |
| 4.1.2 Anode and cathode | |
| 4.1.3 Electronic electrode and ionic electrode | |
| 4.1.4 Polarizable and nonpolarizable electrodes | 89 |
| 4.2 The Interface of Two Condensed Phases | 90 |
| 4.2.1 Potential difference between two contacting phases | 90 |
| 4.2.2 The interface of zero charge | 93 |
| 4.2.3 Interfaces in charge transfer equilibrium | 94 |
| 4.3 Electrode Potential | |
| 4.3.1 Electrode potential defined by electron energy levels | |
| 4.3.2 Electrode potential and ion energy levels in electrodes | 101 |
| 4.4 Electrode Potential in Charge Transfer Equilibrium | 103 |
| 4.4.1 Electrode potential in electron transfer equilibrium | 103 |
| 4.4.2 Electrode potential in ion transfer equilibrium | 105 |
| 4.4.3 Potential of film-covered ionic electrodes in equilibrium | 107 |
| 4.4.4 Potential of gas electrodes in equilibrium | |
| 4.5 Measurement of Electrode Potentials | |
| 4.6 Potential of the Emersed Electrode | 112 |
| 4.6.1 Potential of emersed electrodes in vacuum | 113 |
| 4.6.2 Potential of emersed electrodes in inactive gas | |
| References | 117 |
| CHAPTER 5 | |
| ELECTRIC DOUBLE LAYER AT ELECTRODE INTERFACES | 110 |
| 5.1 Solid Surface and Adsorption | |
| 5.1.1 Clean surface of solids | 119 |
| | |
| 5.1.2 Adsorption | |
| 5.1.3 Electron level of adsorbed particles | 197 |
| 5.2.1 Electric double Layer at Sond/Aqueous Solution Interfaces | 107 |
| 5.2.2 Diffuse charge layer (Space charge layer) | 190 |
| 5.3 The Potential of Zero Charge on Metal Electrodes | 129 |
| 5.3.1 Classical model of the compact double layer at interfaces | 190 |
| 5.3.2 The potential of zero charge | 195 |
| 5.3.2 The potential of zero charge | 100 |
| 5.4.1 Gibbs' adsorption equation | 120 |
| 5.4.2 Ion adsorption on mercury electrodes | |
| VIVII MEDVI PRIVIL VII MOI VII J VIOVE VEGO | |

CONTENTS ix

| 5.4.3 Contact adsorption of ions | 142 |
|---|-----|
| 5.5 Electric Double Layer at Metal Electrodes | 143 |
| 5.5.1 Interfacial electric capacity (Electrode capacity) | 143 |
| 5.5.2 The effective image plane on metal surfaces | 144 |
| 5.5.3 The closest approach of water molecules to electrode interfaces | 146 |
| 5.5.4 Electric capacity of the compact layer | 148 |
| 5.5.5 Potential across the compact double layer | 150 |
| 5.6 Contact Adsorption and Electric Double Layer | 151 |
| 5.6.1 Contact adsorption and work function | 151 |
| 5.6.2 Interfacial dipole moment induced by contact adsorption | 153 |
| 5.6.3 Interfacial potential affected by contact adsorption | 155 |
| 5.7 Particle Adsorption on Metal Electrodes | 158 |
| 5.7.1 Adsorption of water molecules | 158 |
| 5.7.2 Coadsorption of water molecules and third-particles | 161 |
| 5.7.3 Surface lattice transformation due to contact adsorption | 162 |
| 5.7.4 Electron energy levels of adsorbed particles | 165 |
| 5.8 Electric Double Layer at Semiconductor Electrodes | 168 |
| 5.8.1 Electric double layer model | 168 |
| 5.8.2 Potential distribution across the electrode interface | 160 |
| 5.9 Band Edge Level Pinning and Fermi Level Pinning | 171 |
| 5.10 The Space Charge Layer of Semiconductor Electrodes | 174 |
| 5.10.1 Space charge layers | 174 |
| 5.10.2 Differential electric capacity of space charge layers | 174 |
| 5.10.3 Schottky barrier | 176 |
| 5.11 The Compact Layer at Semiconductor Electrodes | 181 |
| 5.11.1 Hydroxylation of electrode interfaces | 181 |
| 5.11.1 Hydroxylauon of electrode interfaces | 181 |
| 5.11.2 The compact layer | 184 |
| 5.11.3 Differential electric capacity of electrode interfaces | 187 |
| 5.12 The Surface State of Semiconductor Electrodes | 188 |
| 5.12.1 Surface states | 188 |
| 5.12.2 Differential electric capacity of surface states | 190 |
| 5.13 The Flat Band Potential of Semiconductor Electrodes | 192 |
| 5.13.1 Flat band potential | 192 |
| 5.13.2 Band edge potential | 195 |
| References | 196 |
| | |
| CHAPTER 6 | |
| ELECTROCHEMICAL CELLS | 201 |
| 6.1 Electrochemical Cells | 201 |
| 6.2 Electromotive Force of Electrochemical Cells | 204 |
| 6.3 Equilibrium Potential of Electrode Reactions | 206 |
| 6.3.1 Equilibrium potential of electron transfer reactions | 206 |
| 6.3.2 Equilibrium potential of ion transfer reactions | 208 |
| 6.4 Electrochemical Reference Level for Hydrated Ions | 210 |
| References | 211 |
| | |
| CHAPTER 7 | |
| ELECTRODE REACTIONS | 213 |
| 7.1 Electrode Reactions | 213 |
| 7.1.1 Electron transfer and ion transfer reactions | 919 |
| 7.1.2 Cathodic and anodic reactions | 919 |
| 7.1.3 Electron transfer of hydrated particles and adsorbed particles | 914 |
| 7.2 Reaction Rate | 910 |
| 7.2.1 Forward and backward reaction affinities | 010 |
| 1 OI WALL ALL DACKWALL TEACHOLL MITHURS | Z16 |

x CONTENTS

| 7.2.2 Reaction rate | 917 |
|---|---------------|
| 7.2.3 Polarization curve of electrode reactions | 910 |
| 7.3 Reaction Mechanism | 210 |
| 7.3.1 The stoichiometric number of reactions | 220 |
| 7.3.2 The activation energy | 220 |
| 7.3.3 Quantum tunneling and activated flow of particles | 221 |
| 7.3.4 The reaction order | 223 |
| 7.4 Rate-Determining Steps of Reactions | 225 |
| 7.4.1 Reaction of elementary steps in series | 226 |
| 7.4.2 Reaction rate determined by a single step | 226 |
| 7.4.3 Reaction rate determined by multiple steps | 228 |
| 7.4.4 Affinity distributed to elementary steps | 229 |
| 7.4.5 Rate of multistep reactions | 230 |
| References | 232 |
| 240701 01000 | 233 |
| CHAPTER 8 | |
| ELECTRODE REACTIONS IN ELECTRON TRANSFER | 005 |
| 8.1 Electron Transfer at Metal Electrodes | 995 |
| 8.1.1 Kinetics of electron transfer | 430 |
| 8.1.2 The state density of redox electrons | 230 |
| 8.1.3 Exchange reaction current at the equilibrium potential | 435 |
| 8.1.4 Reaction current under polarization | 240 |
| 8.1.5 Diffusion and reaction rate | 242 |
| 8.2 Electron Transfer at Semiconductor Electrodes | 245 |
| 8.2.1 Semiconductor electrodes compared with metal electrodes | 249 |
| 8.2.2 The conduction band and the valence band mechanisms | 249 |
| 8.2.3 Electron state density in redox electrode reactions | 250 |
| 8.2.4 Exchange reaction current at the equilibrium potential | 252 |
| 8.3 Reaction Current at Semiconductor Electrodes | 254 |
| 8.3.1 Reaction current under polarization | 258 |
| 8.3.2 Reaction current versus potential curve | 258 |
| 8.3.3 The transport overvoltage of minority carriers | . 262 |
| 8.3.4 Recombination of minority carriers | 266 |
| 8.3.5 Polarization curves of redox electron transfers | 267 |
| 8.3.6 Rodow Formi lovel and hand advantages | 268 |
| 8.3.6 Redox Fermi level and band edge level | 270 |
| 8.3.7 Electron transfer via the surface state | 272 |
| 8.3.8 Electron tunneling through the space charge layer | 274 |
| 8.4 Complexation and Adsorption in Electron Transfer Reactions | 274 |
| 8.4.1 Complexation shifts the redox electron level | 274 |
| 9.5 Floaten Thomas The Committee redox electron level | 278 |
| 8.5 Electron Transfer at Film-Covered Metal Electrodes | . 281 |
| 8.5.1 Electron transfer between the electrode metal and the redox particles | .282 |
| 8.5.2 Electron transfer between the film and the redox particles | .284 |
| 8.5.3 Polarization curves observed | . 286 |
| References | .287 |
| CHAPTER 9 | |
| | |
| ELECTRODE REACTIONS IN ION TRANSFER | . 289 |
| 9.1 Metal Ion Transfer at Metal Electrodes | .289 |
| 9.1.1 Metal ion transfer in a single elementary step | .289 |
| 9.1.2 Metal ion transfer in a series of two elementary steps. | . 294 |
| 9.2 Ion Transfer at Semiconductor Electrodes. | . 29 8 |
| 9.2.1 Surface atom ionization of covalent semiconductor electrodes | .298 |
| 9.2.2 Dissolution of covalent semiconductors | .302 |

CONTENTS xi

| 9.2.3 Dissolution of ionic semiconductors | 30{ |
|--|-----|
| 9.2.4 Oxidative and reductive dissolution of ionic semiconductors | 309 |
| 9.3 Ion Adsorption on Metal Electrodes | 314 |
| 9.3.1 Ion adsorption equilibrium | 314 |
| 9.3.2 Electron levels of adsorbed ions | 315 |
| 9.4 Ion Adsorption on Semiconductor Electrodes | 317 |
| 9.4.1 Ion adsorption equilibrium | 317 |
| 9.4.2 Electron levels of adsorbed ions | 917 |
| 9.4.3 Proton levels on electrode surfaces | 319 |
| References | 322 |
| CHAPTER 10 | |
| | |
| SEMICONDUCTOR PHOTOELECTRODES | |
| 10.1 Quasi-Fermi Level of Excited Electrons and Holes | 325 |
| 10.1.1 Quasi-Fermi level | 325 |
| 10.1.2 Quasi-Fermi levels and electrode reactions | 328 |
| 10.2 Photopotential | 330 |
| 10.3 Photoexcited Electrode Reactions | 334 |
| 10.3.1 Photoexcited electrode reaction current (Photocurrent) | 334 |
| 10.3.2 The range of electrode potential for photoelectrode reactions | 338 |
| 10.3.3 The flat band potential of photoexcited electrodes | 344 |
| 10.4 The Rate of Photoelectrode Reactions | 347 |
| 10.4.1 Anodic transfer reactions of photoexcited holes | 347 |
| 10.4.2 Generation and transport of holes | 349 |
| 10.4.3 Interfacial overvoltage of hole transfer | 350 |
| 10.4.4 Recombination of photoexcited holes in anodic reactions | 352 |
| 10.4.5 Cathodic hole injection reactions | 354 |
| 10.5 Photoelectrochemical Cells | 356 |
| 10.6 Photoelectrolytic Cells | 357 |
| 10.6.1 Photoelectrolytic cells of metal and semiconductor electrodes | 357 |
| 10.6.2 Photoelectrolytic cells of two semiconductor electrodes | 364 |
| 10.7 Photovoltaic Cells | 367 |
| References | 371 |
| CHAPTER 11 | |
| | |
| MIXED ELECTRODES | 373 |
| 11.1 The Single Electrode and The Mixed Electrode | 373 |
| 11.2 Catalytic Reactions on Mixed Electrodes | 375 |
| 11.3 Mixed Electrode Potential | 377 |
| 11.4 Passivation of Metal Electrodes | 381 |
| 11.4.1 Polarization curve of anodic metal dissolution | 381 |
| 11.4.2 Metal dissolution in the passive and transpassive states | 383 |
| 11.4.3 Spontaneous passivation of metal electrodes | 387 |
| References | 389 |
| LIST OF SYMBOLS | 391 |
| | |
| INDEX | 907 |

CHAPTER 1

THE ENERGY LEVEL OF PARTICLES

1.1 Particles and Particle Ensembles

Materials and substances are composed of particles such as molecules, atoms and ions, which in turn consist of much smaller particles of electrons, positrons and neutrons. In electrochemistry, we deal primarily with charged particles of ions and electrons in addition to neutral particles. The sizes and masses of ions are the same as those of atoms: for relatively light lithium ions the radius is 6×10^{-11} m and the mass is 1.1×10^{-26} kg. In contrast, electrons are much smaller and much lighter than ions, being 1/1,000 to 1/10,000 times smaller (classical electron radius = 2.8×10^{-15} m, electron mass = 9.1×10^{-31} kg). Due to the extremely small size and mass of electrons, the quantization of electrons is more pronounced than that of ions. Note that the electric charge carried by an electron ($e = -1.602 \times 10^{-19}$ C) is conventionally used to define the elemental unit of electric charge.

In general, a single particle has unitary properties of its own. In addition, a large number of particles constitutes a statistical ensemble that obeys ensemble properties based on the statistics that apply to the particles. According to quantum statistical mechanics, particles with half an odd integer spin such as electron and positron follow the *Fermi statistics*, and particles with an even integer spin such as photon and phonon follow the *Bose-Einstein statistics*. For heavy particles of ions and atoms, which also follow either the Fermi or the Bose-Einstein statistics, both Fermi and Bose-Einstein statistics become indistinguishable from each other and may be represented approximately by the *Boltzmann statistics* in the temperature range of general interest.

Particles that obey Fermi statistics are called *Fermi particles* or *fermions*. The probability density of Fermi particles in their energy levels is thus represented by the Fermi function, $f(\varepsilon)$, that gives the probability of fermion occupation in an energy level, ε , as shown in Eqn. 1–1:

$$f(\varepsilon) = \frac{1}{\exp\left(\frac{\varepsilon - \varepsilon_{\rm F}}{h T}\right) + 1},\tag{1-1}$$

where k is the Boltzmann constant, T is the absolute temperature, and ε_F is the thermodynamic potential of Fermi particle called the *Fermi level* or *Fermi energy*. Fermi statistics permits only one energy eigenstate to be occupied by one particle.

Particles that obey Bose-Einstein statistics are called *Bose particles* or *bosons*. The probability density of bosons in their energy levels is represented by the Bose-Einstein function as shown in Eqn. 1–2:

$$f(\varepsilon) = \frac{1}{\exp\left(\frac{\varepsilon - \varepsilon_{\rm B}}{kT}\right) - 1},\tag{1-2}$$

where ε_B is the thermodynamic potential of Bose particles, called the *Bose-Einstein level* or *Bose-Einstein condensation level*. In Bose-Einstein statistics one energy eigenstate may be occupied by more than one particle.

Figure 1–1 shows the two probability density functions. In Fermi statistics, the probability of particle occupation (Fermi function) becomes equal to unity at energy levels slightly lower than the Fermi level $(f(\varepsilon) = 1)$ at $\varepsilon < \varepsilon_F$ and to zero at energy levels slightly higher than the Fermi level $(f(\varepsilon) = 0)$ at $\varepsilon > \varepsilon_F$, apparently decreasing from one to zero in a narrow energy range around the Fermi level, ε_F ,

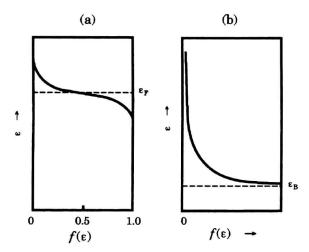


Fig. 1-1. Probability density functions of particle energy distribution: (a) Fermi function, (b) Bose-Einstein function. $\varepsilon =$ particle energy; $f(\varepsilon) =$ probability density function; $\varepsilon_F =$ Fermi level; $\varepsilon_B =$ Bose-Einstein condensation level.

with increasing particle energy. On the other hand, in Bose-Einstein statistics the particle occupation probability decreases nearly exponentially with increasing particle energy above the Bose-Einstein level, ϵ_B . At high energy levels ($\epsilon \gg \epsilon_F$, $\epsilon \gg \epsilon_B$), both Fermi and Bose statistics may be approximated by the classical Boltzmann distribution function shown in Eqn. 1–3:

$$f(\varepsilon) = C \exp\left(\frac{-\varepsilon}{kT}\right),$$
 (1-3)

where C is a normalization constant, and the exponential factor of $\exp(-\varepsilon/kT)$ is called the *Boltzmann factor*. The Boltzmann function is valid for particle ensembles of low density at relatively high temperature.

According to quantum statistics, a particle is in a state of degeneracy if the particle ensemble follows either the Fermi or the Bose-Einstein statistics. We may assume that a particle is in the state of degeneracy at low temperatures and in the state of nondegeneracy at high temperatures. The transition temperature, T_c , (degeneracy temperature) between the two states is proportional to the 2/3 power of particle density, n, and inversely proportional to the particle mass, m. The degeneracy temperature for Fermi particles, that is called the Fermi temperature, is given by $T_c = \varepsilon_F/k = (h^2/8 \, m \, k) \times (3 \, n/\pi)^{2/3}$, where h is the Planck constant. The transition temperature from degeneracy to nondegeneracy is estimated to be about 10,000 K for free electrons in metals and about 1 K for ions and atoms in condensed phases. Electrons in metal crystals, then, are degenerated Fermi particles, while ions and atoms in condensed phases are nondegenerated Boltzmann particles in the temperature range of general interest.

In quantum mechanics, the energy of particles is quantized into a series of allowed energy levels, $\varepsilon_n = n^2 \, h^2 / (\, 8 \, m \, a^2)$; where a is the space size for a particle, m is the particle mass, and n $(n=1, 2, 3, \cdots)$ is the quantum number. The interval of allowed energy levels is then given by $\Delta \varepsilon = \varepsilon_{n+1} - \varepsilon_n = (\, 2 \, n + 1 \,) \, h^2 / (\, 8 \, m \, a^2 \,)$, indicating that the greater the particle mass and the greater the particle space size, the smaller are the energy level intervals and, hence, the less are the quantization effects. The transition from the quantized energy levels to the continuous energy levels corresponds to the degeneracy—nondegeneracy transition of particle ensembles.

The particles we will deal with in this textbook are mainly electrons and ions in condensed solid and liquid phases. In condensed phases ions are the classical Boltzmann particles and electrons are the degenerated Fermi particles.

1.2 Chemical Potential and Electrochemical Potential

According to classical thermodynamics, the energy of particles may be represented in terms of entropy, internal energy, enthalpy, free energy, and free enthalpy, depending on the independent variables we choose to describe the state of particle ensemble system. We use in this textbook the free enthalpy, G, (also called the Gibbs free energy or Gibbs energy) with independent variables of temperature, T, and pressure, P; and the free energy, F, (also called the Helmholtz free energy) with independent variables of temperature, T, and volume, T.

The differential energy of a substance particle, i, in a particle ensemble is called the *chemical potential*, μ_i , when the particle is electrically neutral (atoms and molecules),

$$\mu_{i} = \left(\frac{\partial G}{\partial x_{i}}\right)_{p,T,x} = \left(\frac{\partial F}{\partial x_{i}}\right)_{V,T,x}; \tag{1-4}$$

and the differential energy is called the *electrochemical potential*, $\overline{\mu}_i$, when the particle is electrically charged (ions and electrons),

$$\bar{\mu}_{i} = \left(\frac{\partial G}{\partial x_{i}}\right)_{p,T,x,\phi} = \left(\frac{\partial F}{\partial x_{i}}\right)_{V,T,x,\phi}; \tag{1-5}$$

where x_i is the molar fraction of particle i and ϕ is the inner potential (electrostatic potential) of the particle ensemble. In Eqns. 1–4 and 1–5 we may use, instead of the molar fraction, x_i , the particle concentration, n_i , in terms of the number of particles in unit volume of the particle ensemble. For an ensemble comprising only the same particles of pure substance, the chemical potential becomes equal to the free enthalpy or free energy divided by the total number of particles in the ensemble $(\mu_i = G/N_i = F/N_i)$, and so does the electrochemical potential $(\bar{\mu}_i = G/N_i = F/N_i)$. The chemical potential may be defined not only for non-charged neutral particles but it can also be defined for charged particles by subtracting the electrostatic energy from the electrochemical potential of a charged particle, as is shown in Eqn. 1–9.

For an ensemble comprising a mixture of different kinds of substance particles, chemical thermodynamics introduces the *absolute activity*, λ_1 , to represent the chemical potential, μ_i , of component i as shown in Eqn. 1–6:

$$\mu_i = k T \ln \lambda_i . \tag{1-6}$$

Further, introducing a standard state (reference state) where the chemical potential of component i is μ_i^* and the absolute activity is λ_i^* , we obtain from Eqn. 1–6 the following equation:

$$\mu_i - \mu_i^* = k T \ln \frac{\lambda_i}{\lambda_i^*}. \tag{1-7}$$

The ratio $\lambda_i/\lambda_i^* = a_i$ is called the *relative activity* or simply the *activity*, which of course depends on the standard state chosen. In general, the standard state of substances is chosen either in the state of pure substance $(x_i \to 1)$ based on the Raoult's law $[\mu_i^* = (\partial G/\partial x)_{x\to 1}]$ or in the state of infinite dilution $(x_i \to 0)$ based on the Henry's law $[\mu_i^* = (\partial G/\partial x)_{x\to 0}]$.

The ratio of the activity, a_i , to the molar fraction, x_i , or to the concentration, n_i , is the activity coefficient, $\gamma_i = a_i/x_i$ or $\gamma_i = a_i/n_i$. Then, Eqn. 1-7 yields Eqn. 1-8:

$$\mu_{i} = \mu_{i}^{*} + k T \ln a_{i} = \mu_{i}^{*} + k T \ln \gamma_{i} + k T \ln x_{i}. \tag{1-8}$$

The chemical potential, μ_i^* , in the standard state defines the "unitary energy level" of component i in a particle ensemble, and the term $kT\ln(\gamma_i x_i)$ is the communal energy, in which the term $kT\ln x_i$ is called the cratic energy representing the energy of mixing due to the indistinguishability of identical particles in an ensemble of particles [Gurney, 1953].

For charged particles an electrostatic energy of $z_i e \phi$ has to be added to the chemical potential, μ_i , to obtain the electrochemical potential, μ_i , as shown in Eqn. 1-9:

$$\bar{\mu}_{i} = \mu_{i} + z_{i} e \phi = \mu_{i}^{*} + k T \ln \alpha_{i} + z_{i} e \phi . \tag{1-9}$$

where z_i is the charge number of component i, e is the elemental charge, and ϕ is the electrostatic inner potential of the ensemble.

1.3 Electrochemical Potential of Electrons

For high density electron ensembles such as free valence electrons in solid metals where electrons are in the state of degeneracy, the distribution of electron energy follows the Fermi function of Eqn. 1–1. According to quantum statistical dynamics [Davidson, 1962], the *electrochemical potential*, μ_{\bullet} , of electrons is represented by the Fermi level, ϵ_{F} , as shown in Eqn. 1–10:

$$\bar{\mu}_{e} = \left(\frac{\partial G}{\partial n_{e}}\right)_{p,T,x,\phi} = \left(\frac{\partial F}{\partial n_{e}}\right)_{V,T,x,\phi} = \varepsilon_{F}, \qquad (1-10)$$

where n_{\bullet} is the electron concentration in the electron ensemble.

The "state density", $D(\varepsilon)$, of electrons is defined as the number of energy eigenstates, each capable of containing one electron, for unit energy interval (energy differential) for unit volume of the electron ensemble. According to the electron theory of metals [Blakemore, 1985], the state density of free electrons in metals is given by a parabolic function of electron energy ε as shown in Eqn. 1–11:

$$D(\varepsilon) = \frac{1}{2\pi^2} \left(\frac{2m_e}{\hbar^2} \right)^{\frac{2}{3}} (\varepsilon - \varepsilon_0)^{\frac{1}{2}}, \qquad (1-11)$$

where ε_0 is the potential energy of electrons (the Hartree potential) in metals. The concentration, $n_{\bullet}(\varepsilon)$, of electrons that occupy the eigenstates at an energy level of ε is given by the product of the state density and the probability density of Fermi function as in Eqn. 1-12:

$$n_{e}(\varepsilon) = D(\varepsilon) \cdot f(\varepsilon) = \frac{D(\varepsilon)}{\exp\left(\frac{\varepsilon - \varepsilon_{F}}{k T}\right) + 1} . \tag{1-12}$$

Similarly, the concentration of eigenstates vacant of electrons is given by Eqn. 1-13:

$$D(\varepsilon) - n_{\rm e}(\varepsilon) = D(\varepsilon) \left\{ 1 - f(\varepsilon) \right\} = \frac{D(\varepsilon)}{\exp\left(\frac{\varepsilon_{\rm F} - \varepsilon}{k T}\right) + 1} \ . \tag{1-13}$$

It follows from Eqns. 1–12 and 1–13 that the state density is *half occupied* by electrons with the remaining half vacant for electrons at the Fermi level, ε_F , as shown in Fig. 1–2. Since the Fermi temperature of electrons $(T_c = \varepsilon_F/k)$ in electron

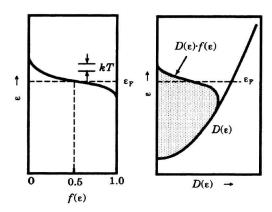


Fig. 1–2. Energy distribution of electrons near the Fermi level, ε_F , in metal crystals: $\varepsilon =$ electron energy; $f(\varepsilon) =$ distribution function (probability density); $D(\varepsilon) =$ electron state density; $D(\varepsilon) f(\varepsilon) =$ occupied electron state density.